EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	183	porous near5 (support or wafer or substrate) same (mask\$4 or masq \$4 or mask\$4 or latex) and (array or microarray) and (metal near2 oxide or metal \$40xide or metal\$4 near2 oxide)	US-PGPUB; USPAT	OR	ON	2009/09/17 09:53
L2	45	L1 and ("422" "435" "436").clas.	US-PGPUB; USPAT	OR	ON	2009/09/17 09:53
L3	1	"20050003521".pn. and porous	US-PGPUB; USPAT	OR	ON	2009/09/17 11:01
L4	1	"20050003521".pn. and mask\$4	US-PGPUB; USPAT	OR	ON	2009/09/17 11:05
L5	0	"20050003521".pn. and mask\$4 same polymer \$4	US-PGPUB; USPAT	OR	ON	2009/09/17 11:07
L6	1	"20050003521".pn. and polymer\$4	US-PGPUB; USPAT	OR	ON	2009/09/17 11:07
L7	1	"5843767".pn.	US-PGPUB; USPAT	OR	ON	2009/09/17 11:09
L8	1	"6635226".pn.	US-PGPUB; USPAT	OR	ON	2009/09/17 11:12
L9	3	ptfe with mask\$4 same mems	US-PGPUB; USPAT	OR	ON	2009/09/17 11:19
L10	7	pmma with mask\$4 same mems	US-PGPUB; USPAT	OR	ON	2009/09/17 11:21
L11	545	mask same microarray	US-PGPUB; USPAT	OR	ON	2009/09/17 12:09
L12	77	mask same microarray and 435/287.2.cds.	US-PGPUB; USPAT	OR	ON	2009/09/17 12:09
L13	14	mask same microarray and 435/287.2.ccls.	USPAT	OR	ON	2009/09/17 12:09
L14	24	mask\$4 same microarray and 435/287.2.ccls.	USPAT	OR	ON	2009/09/17 12:09

L15	13	("5266471" "5474895" "5514785" "5667976" "5690894" "5919523" "6013789").PN. OR ("6387631").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/17 12:10
L16	1	"6387631".pn. and polymer\$4 with ∞at\$4	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/17 12:31
L17	1	"6387631".pn. and mask \$4	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/17 12:31
L18	0	"6387631".pn. and oxide	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 12:38
L19	0	"6387631".pn. and aluminum	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 12:38
L20	0	"6387631".pn. and latex	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 12:42
L21	0	"6387631".pn. and (vinyl near2 acetate or SBR or \$butadiene or acrylat\$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 12:48
L22	5	15 and (vinyl near2 acetate or SBR or \$butadiene or acrylat\$4 or latex)	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 12:48
L23	1	"20050003521".pn. and kit	US-PGPUB; USPAT	OR	ON	2009/09/17 12:49
L24	38	("4319975" "4337154" "4391904" "4739044" "4806546" "5011861" "5082935").PN. OR ("5667976").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/17 13:52
L25	1	"20050003521".pn. and hybridizat\$4	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/17 14:26
L26	1675	(array or microarray) same latex	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 14:31
L27	221	(array or microarray) same latex with (mask \$4 or coat\$4)	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 14:31
L28	77	(array or microarray) same latex with (mask \$4 or coat\$4) and ("422" or "435").clas.	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 14:31
L29	1	"20020034757".pn. and hybridizat\$4	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/17 15:02
S2	1	"20070202013".pn.	US-PGPUB; USPAT	OR	ON	2009/06/08 15:04

S3	1	"20070202013".pn. and co\$solvent	US-PGPUB; USPAT	OR	ON	2009/06/08 15:07
S4	2	("6103479" "6197575").PN.	USPAT	OR	ON	2009/09/16 11:57
S5	68	(mask\$4 or masq\$4) with support near6 porous	USPAT	OR	ON	2009/09/16 12:12
S6	141	(mask\$4 or masq\$4) with support near6 porous	US-PGPUB; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:12
S7	5	(mask\$4 or masq\$4) with (support near6 porous) same (channel or groove)	US-PGPUB; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:13
S8	1	(mask\$4 or masq\$4) with (support near6 porous) same (channel or groove)	USPAT	OR	ON	2009/09/16 12:14
S9	209	S5 S6	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:18
S10	12	S9 and (metal\$4 near2 oxide or metal\$oxide or metal\$3oxide) with support	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:18
S11	10	"9902266"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:20
S12	2	WO-9902266-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:21
S13	2	"6225131".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:22
S14	1	"6225131".pn.	US-PGPUB; USPAT	OR	ON	2009/09/16 12:23
S15	14	("3652761" "3671410" "4427415" "4693985" "4777021" "5772735" "5843767").PN. OR ("6225131").URPN.	US-PGPUB; USPAT; USOCR	OR	OFF	2009/09/16 12:23
S16	5	S15 and support with (porous or metal near2 oxide or metal\$4 near2 oxide or metal\$oxide or metal\$3oxide)	US-PGPUB; USPAT; USOCR	OR	ON	2009/09/16 12:23
S17	0	"6225131".pn. and (mask\$4 or masq\$4)	USPAT	OR	ON	2009/09/16 12:49

S18	0	"6225131".pn. and (polymer\$4 or agent)	USPAT	OR	ON	2009/09/16 12:49
S19	2	("6225131" "5772735" "5843767" "3671410" "4693985" "20090042736").pn. and (mask\$4 or grid or polymer near5 (print\$4 or introduc\$5))	US-PGPUB; USPAT	OR	ON	2009/09/16 12:54
S20	1	"5843767".pn. and porous	US-PGPUB; USPAT	OR	ON	2009/09/16 12:55
S21	0	"5843767".pn. and (metal near3 oxide or metal\$4 near3 oxide or metal\$oxide or metal \$4oxide)	US-PGPUB; USPAT	OR	ON	2009/09/16 12:55
S22	20	S9 and (metal\$40xide or metal\$4 near3 oxide or metal near3 oxide) with (support or wafer or substrate)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 12:57
S2 3	3	"03089136"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 13:02
S24	0	WO03089136	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 13:03
S 25	979	porous near5 (support or wafer) same (mask\$4 or masq\$4 or mask\$4 near3 grid or grid or polymer near4 print\$4)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 14:29
S26	150	porous near5 (support or wafer) same (mask\$4 or masq\$4 or mask\$4 near3 grid or grid or polymer near4 print\$4) and (metal\$4 near3 oxide or metal\$oxide or metal\$4oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 14:30
S27	4	porous near5 (support or wafer) same (mask\$4 near3 grid)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 14:30

S28	24	porous near5 (support or wafer) same (mask\$4 or masq\$4 or mask\$4 near3 grid or grid or polymer near4 print\$4) and (metal\$4 near3 oxide or metal\$oxide or metal\$4oxide) with support	US-PGPUB; USPAT; EPO; JPO; DERWENT	TOR		2009/09/16
S29	27	(array or microarray) near4 analy\$5 and mask \$4 near5 grid and porous	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 14:33
S30	29	blok.in. and mask\$4	US-PGPUB; USPAT	OR	ON	2009/09/16 14:39
S31	11	blok.in. and mask\$4 and porous	US-PGPUB; USPAT	OR	ON	2009/09/16 14:39
S32	1	WO-03089136-\$.did.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 14:47
\$33	1	WO-03089136-\$.did.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/16 14:48
S34	1	2004-011674.NRAN.	DERWENT	OR	OFF	2009/09/16 14:48
S35	O	"20060057032".pn. and (mask\$4 or agar)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/16 14:54
S36	2	"20060057032".pn. and (porous)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/16 14:54
S 37	1	"20060057032".pn. and (grid or polymer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM TDB	OR	ON	2009/09/16 14:55

S38	0	"20060057032".pn. and (grid)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/16 14:55
S39	0	"20060057032".pn. and (grid or polymer)	US-PGPUB	OR	ON	2009/09/16 15:14
S40	0	"200700721870".pn. and (grid or polymer)	US-PGPUB	OR	ON	2009/09/16 15:14
S41	0	"200700721870".pn.	US-PGPUB	OR	ON	2009/09/16 15:14
S42	1	"20070072187".pn.	US-PGPUB	OR	ON	2009/09/16 15:15
S43	1	"20070072187".pn. and mask	US-PGPUB	OR	ON	2009/09/16 15:20
S44	13	S28 and (latex or vinyl near2 acetate or acrylate or SBR or styrene\$)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2009/09/16 15:43
S45	2	"20060057032".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/09/16 16:37
S46	1	"20060057032".pn.	US-PGPUB	OR	ON	2009/09/16 16:37
S47	1786	porous near5 (support or wafer or substrate) same (mask\$4 or masq \$4 or mask\$4 or latex)	US-PGPUB; USPAT	OR	ON	2009/09/16 16:38
S48	631	porous near5 (support or wafer or substrate) same (mask\$4 or masq \$4 or mask\$4 or latex) and (array or microarray)	US-PGPUB; USPAT	OR	ON	2009/09/16 16:38
S49	183	porous near5 (support or wafer or substrate) same (mask\$4 or masq \$4 or mask\$4 or latex) and (array or microarray) and (metal near2 oxide or metal \$4oxide or metal\$4 near2 oxide)	US-PCPUB; USPAT	OR	ON	2009/09/16 16:39

S50	5	porous near5 (support or wafer or substrate) same (mask\$4 or masq \$4 or mask\$4 or latex) and (array or microarray) and (metal near2 oxide or metal \$4oxide or metal\$4 near2 oxide) and latex with mask\$4	US-PGPUB; USPAT	OR	ON	2009/09/16 16:41
S51	45	S49 and ("422" "435" "436").clas.	US-PGPUB; USPAT	OR	ON	2009/09/16 16:42
S52	308	435/287.2.ccls. and porous near5 (support or wafer or substrate) and (mask\$4 or masq \$5)	US-PGPUB; USPAT	OR	ON	2009/09/16 16:48

EAST Search History (Interference)

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